



Industrial Instruments General Brochure

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Stereo Microscopes

The highly cost-effective SMZ series offer outstanding optical performance, flexible system expandability, and superb operability.

		_	Parallel Opt
	SMZ25		SMZ18
Zoom Ratio	25 : 1		18 : 1
Zoom Range	0.63–15.75×		0.75–13.5×
Total Magnification*1 (Standard combination*2)	3.15–945× (6.3–157.5×)		3.75–810× (7.5–135×)
WD *3	60 mm		60 mm
Camera	\checkmark		\checkmark



*1: Depending on combination of Eyepiece and Objective lens. *2: Combination of Eyepiece 10x and Objective lens 10x. *3: Objective lens 1x or no Auxiliary lens.

SMZ Series



SMZ SMZ		SMZ-2			
:1	4.3 : 1	5 : 1			
-3.5×	0.7 –3×	0.8-4×			
70× 35×)	3.5–60× (7–30×)	4–120× (8–40×)			
100 mm		77.5 mm			
_					
✓ : Available / — : Not available					

Industrial Microscopes

Nikon's Industrial Microscopes utilize the CFI60-2 optical system, highly evaluated for providing a high NA combined with long WD.



BF: Brightfield DF: Darkfield DIC: Differential Interference Contrast FL: Fluorescence POL: Polarizing 2-Beam: Two-Beam Interferometry Ph-C: Phase-Contrast

	Upright Microscopes (Large-sized stage model)							
	L200N	L300N						
	L200ND	L300ND						
	Stage with stroke 200×200 mm is available. Suitable for ø200 mm wafer observation.	Stage with stroke 350×300 mm is available. Suitable for ø300 mm wafer observation.						
Observation Method	BF DF DIC S-POL FL EPI ✓ ✓ ✓ ✓ ✓ DIA ✓* — — — — *L200ND only ✓ ✓ ✓ Istantial Istantial	BF DF DIC S-POL FL EPI ✓ ✓ ✓ ✓ ✓ DIA ✓* — — ✓ — *L300ND only ✓ : Available / — : Not available						
Illuminator	 L200N : Episcopic L200ND : Episcopic / Diascopic 	L300N : Episcopic L300ND : Episcopic / Diascopic						
Stage	• 8×8 Stage (stroke: 200×200 mm) • 14×12 Stage (stroke: 350×300 mm)							
	BF: Brightfield DF: Darkfield DIC: Differential Interference Contrast S-POL:	Simple Polarizing FL: Fluorescence						

brightfield and simple polarizing observations.

MA100N

MA100N is compact,

inverted microscopes

designed for

			БГ		3-PUL	DIC	FL			
ervation		EPI	\checkmark	_	\checkmark	_	_			
od		 ✓ : Available / — : Not available *Dedicated reflected illumination models. 								
inator	• Episcopic									
le	 MA-SR-N Rectangular 3-plate Stage N (stroke 50×50 mm) MA-SP-N Plain Stage N TS2-S-SM Mechanical Stage CH (stroke 126×78 mm) *Please use in combination with MA-SP-N Plain stage N. 									

BF: Brightfield DF: Darkfield DIC: Differential Interference Contrast S-POL: Simple Polarizing FL: Fluorescence

	Pola	arizing Micros	copes
	LV1	IOONPOL	
	perfo a wid applic	anding optical rmance, perfect for e variety of imaging cations and polarizing iques.	
		BF	POL
vation	EPI	\checkmark	\checkmark
d	DIA	\checkmark	\checkmark
		\checkmark	': Available / — : Not available
nator	• Epis	copic/ Diascopic	
	• High obser	n precision rotating stage vation	e for polarizing
	BF: Brightf	ield POL: Polarizing DF: Darkf	ield DIC : Differential Interference (

ECLIPSE Series



Compact polarizing microscope that balances optical performance and ease of use.





Microscope Camera

Digital Sight 1000

Equipped with a 2 megapixel CMOS image sensor, it can capture full HD microscope images. By connecting a microscope to this camera and HDMI monitor, movies and images can be captured and saved onto a pre-inserted SD card in the camera.

DS-Fi3

Three main features of the previous models, high-resolution, high sensitivity and low noise, and highspeed live display are offered in 1 camera.

Digital Sight 10

This high-resolution camera captures both color and monochromatic images at up to $6,000 \times 3,984$ pixels. This enables the wide range of images to be captured and then many of them to be stitched together making a single and large combined image.





Intuitive control of microscope cameras from tablet PCs

Easily view images and control image acquisition settings for the Digital Sight 1000/ DS-Fi3/Digital Sight 10 camera on a tablet PC using NIS-Elements L.

 \oplus

Circle

(Compatible OS: Windows® 10 Pro)

* Nikon provides confirmed compatible tablet PCs with up-to-date specifications. Contact Nikon for details.

User Interface for naturally simple operation

NIS-Elements L displays various menus for image capture, saving, display, measurement and annotations using intuitive icons. It also supports touch screen operation.



Scene mode

Ten camera setting patterns for optimal color reproduction and contrast for each microscope light source, observation method and type of sample, as well as custom settings, can be selected.

Industrial Scene Mode • Wafer/IC • Metal • Circuit board • Flat Panel Display

A wide variety of tools

NIS-Elements L enables the conducting of simple measurements on images, with input of lines and comments. These can also be written onto and saved with the image, and measurement data can be output.



Vertical scale



Nikon's universal software platform, NIS-Elements combines powerful image acquisition, analysis, visualization and data sharing tools. With fully customizable user interfaces and seamless integration of Nikon microscopes, cameras and a wide variety of peripheral devices, NIS-Elements can serve as a simple interface for photo-documentation or power complex, conditional workflows with automated imaging and analysis routines. The NIS-Elements platform features various packages and software modules to meet the needs of even the most challenging applications.

HDR (High Dynamic Range) image acquisition

HDR creates an image with appropriate Ar Option Br D brightness in both the dark and bright

regions in a sample by combining multiple images acquired with different exposure settings. It is also possible to create HDR image using multiple captured images.





Manual measurement and image annotation

Manual Measurement allows easy measurement Ar Br D

of length and area by drawing lines or an object directly on the image. The results can be attached to the image, and also exported as text or to an Excel spreadsheet.



Digital Sight Series

Integration with Nikon's Software Imaging Platform

EDF (Extended Depth of Focus)

Creates a single, all-in-focus image from **Option Ar Br D** images of differing focus. Such images can now be created by simply turning the focus knob.



Selects the in-focus area and produces one all-in-focus image

Auto measurement (Object Counting)

Performs binarization on images using previously set thresholds to measure the number, area, brightness, etc. of identified objects.







Objective Lenses

CFI60-2 / CFI60

Nikon's CFI60-2/CFI60 optical systems are highly evaluated for their unique concept of high NA combined with a long working distance. These lenses have been developed further and evolved achieving the apex in long working distance specifications, correct chromatic aberration, and an optimized lens weight.

Unite Fuer Sciences	TI Plan Five Description	Turban France 2020-05 J and the off	Street France	NAME PLAN MOREONO MARINA MARINA

NA: Numerical Aperture BF: Brightfield DF: Darkfield POL: Polarizing S-POL: Simple Polarizing DIC: Differential Interference Contrast UV-FL: UV Fluorescence FL: EPI Fluorescence

	Model	Magnification	NA	WD (mm)	BF	DF	POL	S-POL	DIC	UV-FL	FL
	T Plan EPI	1×	0.03	3.8		—	—	—	—	_	—
ти	Plan (Semi-apochromat)	2.5×	0.075	6.5	~	—	—	—	—	—	—
	TU Plan Fluor EPI	5×	0.15	23.5	~	—	_	~	✓A	~	\checkmark
	Universal Plan Fluor (Semi-apochromat)	10×	0.3	17.5	✓	-	—	~	νA	~	\checkmark
		20×	0.45	4.5	✓	_	—	~	νA	~	\checkmark
		50×	0.8	1.0	✓	—	-	~	νA	~	\checkmark
		100×	0.9	1.0	│	—	—	~	νA	~	\checkmark
	TU Plan Apo EPI	50×	0.8	2.0	~	-	-	~	νA	—	\checkmark
TU Un	Universal Plan Apo (Apochromat)	100×	0.9	2.0	│	—	—	~	νA	—	\checkmark
		150×	0.9	1.5	│	-	-	~	νA	—	\checkmark
	TU Plan Fluor EPI P	5×	0.15	23.5	~	-	~	~	νA	~	\checkmark
	Polarizing Universal Plan Fluor (Semi-apochromat)	10×	0.3	17.5	✓	_	~	\checkmark	νA	~	\checkmark
		20×	0.45	4.5	│	-	~	~	νA	~	\checkmark
		50×	0.8	1.0	│	_	~	~	νA	~	\checkmark
сгі э		100×	0.9	1.0			\checkmark	\checkmark	νA	\checkmark	\checkmark
CFI60-2	TU Plan EPI ELWD	20×	0.4	19.0	~	-	-	\checkmark	vВ	_	\checkmark
	Long Working Distance Universal Plan (Semi-apochromat)	50×	0.6	11.0	│	—	_	\checkmark	VВ	_	\checkmark
-	(Jenn-apoentornat)	100×	0.8	4.5	✓	-	-	~	VВ	-	\checkmark
	T Plan EPI SLWD	10×	0.2	37.0	~	-	-	-	—	—	\checkmark
	Super Long Working Distance Plan (Semi-apochromat)	20×	0.3	30.0	✓		—	—	—		\checkmark
	(Semi-apochiomat)	50×	0.4	22.0		-	_	—	_	—	\checkmark
		100×	0.6	10.0	│	-	-	—	—	—	\checkmark
	TU Plan Fluor BD	5×	0.15	18.0	~	~	-	~	νA	~	\checkmark
	Universal Plan Fluor (Semi-apochromat)	10×	0.3	15.0	│	~	—	\checkmark	νA	~	\checkmark
		20×	0.45	4.5	│	~	_	~	νA	~	\checkmark
		50×	0.8	1.0	│	~	_	\checkmark	νA		\checkmark
		100×	0.9	1.0	✓	~	-	~	νA	~	\checkmark
	TU Plan Apo BD	50×	0.8	2.0	✓	~	_	~	νA	_	\checkmark
	Universal Plan Apo (Apochromat)	100×	0.9	2.0			—	~	νA	—	\checkmark
		150×	0.9	1.5		~	-	\checkmark	νA	—	\checkmark
	TU Plan BD ELWD	20×	0.4	19.0	│			~	∨В		\checkmark
	Long Working Distance Universal plan (Semi-apochromat)	50×	0.6	11.0				~	✓В	_	\checkmark
	(100×	0.8	4.5		~	-	~	VВ	_	\checkmark
	L Plan EPI (Achromat)	40×	0.65	1.0	~	_	-	-	-	-	\checkmark
	LU Plan Apo EPI / Universal Plan Apo (Apochromat)	150×	0.95	0.3	~	-	-	\checkmark	νA	—	\checkmark
	L Plan EPI CR	20×	0.45	10.9–10.0	~	_	_	-	_	-	\checkmark
	LCD Substrate Inspection Plan (Achromat)	50×	0.7	3.9–3.0		-	—	—	—	_	\checkmark
	*Offers valid while supplies last	100×	0.85	1.2-0.85		_	-	-	—	-	\checkmark
CFI60		100×	0.85	1.3-0.95	~	_	_	-	_		\checkmark
	LE Plan EPI (Achromat)	5×	0.1	31		_	_	-	—	—	\checkmark
		10×	0.25	13		_	_	-	-	-	\checkmark
		20×	0.4	3.6	✓	_	—	—	_	_	\checkmark
		50×	0.75	0.5	✓	—	_	—	—	—	\checkmark
		100×	0.9	0.31		_	-	-	-	_	\checkmark

✓ : Available / — : Not available *A: Set prism position at A / B: Set prism position at B

For Incorporation into Microscopes

Modular Focusing Units

IM-4, LV-IM/LV-IMA, LV-FM/LV-FMA

Suitable for incorporating into systems, these focusing units enable the mounting of a universal illuminator and a motorized nosepiece.

	IM-4	LV-IM/LV-IMA	L
Туре	Manual	Manual / Motorized	M
Vertical stroke	30 mm	30/20 mm	

Compact Reflected Microscopes

CM Series

Ultra-compact reflected microscopes designed for integration into production lines to observe on monitors.



	CM-10A/CM-10L	CM-20A/CM-20L			
Camera mount					
Tube lens magnification	1×	0.5×			
Tube lens focal distance	200 mm	100 mm			
Magnification on CCD surface	Same as objective magnification	Same as objective magnification ×0.5			
Compatible objectives		A series: CF IC EF L series: CFI60-2 / CFI			
Illumination optical system		Koehler illuminati			
Attached surfaces	3				
Dimensions (W×D×H)	40×40×224.5 mm	40×40×125.5 mm			
Weight (approx)	440 g	290 g			

Wafer Loaders

Nikon's proprietary technology ensures reliable loading of ultra-thin 100 µm wafers. The NWL 200 series achieve highly reliable loading, suitable for inspection of next-generation semiconductors.

	Diameter	ø200 mm / ø150 m
Wafer	Minimum thickness (standard)	300 um
	Minimum thickness (option)	100 um
Surface	, back side macro inspection	\checkmark

*Optional special wafer loader is also available. Please ask Nikon for detail.

CNC Video Measuring Systems iNEXIV Series / NEXIV Series

Wide variety of stage strokes and magnifications are available for various customer requirements.

Main Body (Type / Stage Stroke) Wide FOV Model Standard Model High-precision Model VMA VMZ-S VMZ-H Model VMA-2520 Model VMZ-H3030 Model VMZ-S3020/VMZ-S4540/VMZ-S6555 VMA-4540 Applications Micro boards (line Applications Semiconductor packages, high density PCB's, lead frames, VMA-6555 MEMS, connectors, precision mechanical parts, etc. width, height), next-generation Applications Electronic parts, semiconductor packages (WLP, resin molding parts, various bump height), precision molds, mold parts, press parts, die rewiring masks, MEMS masks, etc. cast parts, etc. iNEXIV VMA-4540 NEXIV VMZ-S3020 NEXIV VMZ-S4540 NEXIV VMZ-H3030 Model Wide FOV Standard High-precision 250×200 mm 450×400 mm | 650×550 mm | 300×200 mm | 450×400 mm 650×550 mm 300×300 mm XY Stroke Wide FOV Head \checkmark \checkmark \sim \checkmark \checkmark \checkmark Standard Head \checkmark \checkmark \checkmark \checkmark High-Magnification Head 1 \checkmark

Junioanon roaa							
roke	200 mm	200 mm	200 mm	200 mm 200 mm		200 mm	150 mm
anteed loading capacity	15 kg	20 kg	30 kg	20 kg 40 kg		50 kg	30 kg
n permissible error E Euy, Mpe)	2+8 <i>L</i> /1000 µm	2+6 <i>L</i> /1000 µm		1.2+4 <i>L</i> /1000 µm			0.6+2 <i>L</i> /1000 µm
n permissible error	3+ <i>L</i> /50 μm	3+ <i>L</i> /100 μm		1.2+5 <i>L</i> /1000 μm			0.9+ <i>L</i> /150 µm

L = Length in mm

Z-axis Str

Max. guara Maximun

(EUX, MPI

Maximun (Fuz MP

Type A



comfortable operation. Laser AF and Touch Probe can be attached as optional accessories.

*Touch Probe is an option only for VMA series.

Zoom Heads



(Through the Lens) Laser AF is a standard tool that can scan surfaces at 1000 points/second.



measurements of small targets up to several micrometers.



Simultaneous wide-area height measurements with confocal optics and 2D measurement with 15x brightfield zoom optics.

	Main Body (Type /Stage Stro VMZ-K3040	oke) VMZ-K6555
XY Stroke	300×400 mm	650×550 mm
Magnification (Type S)	1.5× / 3× / 7.5×	1.5× / 3× / 7.5×
Magnification (Type H)	15×/30×	15×/30×
Z-axis Stroke	150 mm	150 mm
Max. guaranteed loading capacity	20 kg	30 kg
Maximum permissible error (Eux, MPE Euy, MPE)	1.5+4 <i>L</i> /1000 μm	1.5+2.5 <i>L</i> /1000 μm
Maximum permissible error (Euz, MPE)	1+ <i>L</i> /1000 µm	1+ <i>L</i> /1000 μm
	(Applications) Micro wiring patterns (top and both	tom), bonding wires, probe cards, WLP, PLP, etc.

FOV	W (mm)× D (mm)	8 6	4 3	2.0 1.5	1.6 1.2	1.26 0.95	1.00 0.75
Type S	1.5×	•					
	3×		•				
	7.5×				•		
Туре Н	15×					-	
	30×						

Confocal NEXIV incorporates confocal optics for fast and accurate evaluation of fine three-dimensional geometries. Confocal Optics are designed for wide FOV height measurement.

High Contrast and Multileveled Sample (PCBs)

Brightfield observation can sometimes be difficult due to blurred lines along sample structure. These lines can be clearly observed and measured using Confocal optics.





Top detected

Bottom detected

Please refer to individual product brochures for further details.

Confocal NEXIV Series

0.27 0.20 0.11 0.100 0.05 0.53 0.63 04 0.47 0.40 0.3 0.20 0.15 0.08 0.074 0.04 WD 24 mm -0 24 mm 5 mm 20 mm ___ 5 mm Brightfield Confocal/Brightfield







Thin Transparent Samples (Metal Surface Film / Semiconductor Resist

Top layers of both thin transparent film and metal surface can be easily detected using Confocal optics.





Measuring Microscopes

Basic Model Large-Stage Model **Compact Model** Focused on high-precision and easy operability, a wide MM-200 MM-400 MM-800 range of MM-products are available. <u>50×50 mm / 5 kg</u> \checkmark \checkmark \checkmark 100×100 mm / 15 kg \checkmark \checkmark _ Stage Size/ 150×100 mm / 15 kg ____ \checkmark \checkmark Loading 200×150 mm / 20 kg \checkmark _ _ Capacity 250×150 mm / 20 kg \checkmark ____ 300×200 mm / 20 kg _ ____ \checkmark Max. Sample Height 110 mm 150 mm 200 mm Monocular Optical \checkmark \checkmark _ Head Binocular \checkmark 1 2-axis \checkmark \checkmark \checkmark X-Y-Z 3-axis \checkmark \checkmark _ CCD \checkmark^* \checkmark \checkmark 1×/3×/5×/10×/20×/50×/100× Obj. Magnification 1×/3×/5×/10×

*For simple video head only









✓ : Available / — : Not available

High-Precision Stages

The coarse/fine changeover lever and the RESET and SEND buttons are located near the X- and Y-axis knobs.







X-axis Knob

Y-axis Knob

17

Focusing Aid (FA)

- The Split-Prism FA delivers sharp patterns
- to allow accurate focusing during Z-axis measurements.

FA patterns are clearly visible because they are split vertically





Objective

Rear Focus

Profile Projectors

Nikon's profile projectors apply the principles of optics to the inspection of manufactured parts by projecting magnified silhouettes on a screen.



	50×50 mm / 5 kg	\checkmark
	100×100 mm / 15 kg	\checkmark
Stage Size/ Loading	150×100 mm / 15 kg	\checkmark
Capacity	200×150 mm / 20 kg	\checkmark
	250×150 mm / 20 kg	\checkmark
Max. Sample	e Height	100 mm* ²
Screen		305 mm
Image		Erect
Projection	Magnification	5×/10×/20×/25×/50×/100×/2
Lens	FOV (with 10× lens)*1	30.5 mm
Digital Protra	ictor	\checkmark
Digital Count	er	\checkmark

*1: Actual FOV = Effective diameter of screen / Lens magnification

*2: Maximum sample height is 70 mm when 200×150 mm stage is installed.

Data Processing Systems for Measuring Microscopes and Profile Projectors



Provides the user with various advanced measurements and processing functions. Automated edge detection with sub-pixel processing enables more precise and repeatable measurements.



	Large-Screen Model V-20B
	\checkmark
	150 mm
	500 mm
	Inverted
200×	5×/10×/20×/50×/100×
	50 mm
	\checkmark
	✓
	\checkmark · Available / — · Not available



Autocollimators

Autocollimator is an easy-to-use but precise metrology instrument for angularity, parallelism, perpendicularity, straightness of precision components machine guide-way and many other applications. TR

	Brightfield Type 6B-LED	Darkfield Type 6D-LED	
	Utilizes hallmark Nikon optics to illuminate surface details.	Optimal for measuring small, flat mirrors.	
Observation method		6B-LED: Brightfield, 6D-LED: Darkfie	ld
Readout system	Adjust	ment in viewfield and reading on mic	rometer
Measuring range	30 min	utes of arc (both vertical and horizon	tal axes)
Minimum range		0.5 seconds of arc	

Plane Mirror C

0

Both sides are perfectly parallel, permitting its use as a reference for non-reflective surface. Also useful for measuring extremely small angles where a smaller mirror is desirable. *Wooden case provided.

!	
uter diameter	30 mm
nickness	12 mm
arallelism	2 seconds of arc



Power source

0 to 40°C

retrofitting onto Autocollimator 6B/6D illumination unit.





Optical Flat / Optical Parallel / Standard 300 mm Scale

	observing ringes	
flat in contact sample.	with the	
		Glass (ø130 mm)
sample.		

Standard 300mm Scale

Gauges stage travel accuracy up to 300 mm. Both 10 mminterval sensor patterns and calibrations are provided. Made of the glass with low coefficient of thermal expansion, for minimizing thermal influence. *Within 1 µm against compensation values.

Operating temperature

Optical Pa	rallel	
finished flat a It is used to c a sample by c interference fi	heck the flatness and parallel levels of observing ringes by placing rallel in contact	
	30 mm	
Diameter		
Diameter Thickness	12 mm / 12.12 mm / 12.25 mm / 12.37 mm	

*Optical flats and parallels with greater precision are available by custom orders.

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A WARNING TO ENSURE CORRECT USAGE, READ THE CORRESPONDING MANUALS CAREFULLY BEFORE USING THE EQUIPMENT.



NIKON CORPORATION

Shinagawa Intercity Tower C, 2-15-3, Konan, Minato-ku, Tokyo 108-6290, Japan phone: +81-3-6433-3701 fax: +81-3-6433-3784 https://www.nikon.com/products/industrial-metrology/

NIKON METROLOGY EUROPE NV

Interleuvenlaan 86 8-3001 Leuven, Belgium phone: +32-16-74-01-00 fax: +32-16-74-01-03 E-mail: Sales.Europe.NM@nikon.com http://www.nikonmetrology.com/en-gb NIKON METROLOGY UK LTD. UNITED KINGDOM phone: +44-1332-811-349 fax: +44-1332-639-881 E-mail: Sales.UK.NM@nikon.com NIKON METROLOGY SARL

FRANCE phone: +33-1-60-86-09-76 fax: +33-1-60-86-57-35 E-mail: Sales.France.NM@nikon.com

NIKON METROLOGY GMBH GERMANY phone: +49-211-45-44-69-51 E-mail: Sales.Germany.NM@nikon.com NIKON INSTRUMENTS S.p.A. ITALY phone: +39-055-300-96-01 fax: +39-055-30-09-93

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NIKON METROLOGY, INC.

12701 Grand River Road, Brighton, MI 48116 U.S.A. phone: +1-810-220-4360 fax: +1-810-220-4300 E-mail: Sales.NM-US@nikon.com http://www.nikonmetrology.com/en-us NIKON METROLOGY - MÉXICO MEXICO phone: +52-442-688-5067 E-mail: Sales.NM-MX@nikon.com NIKON INSTRUMENTS (SHANGHAI) CO., LTD. CHINA (Shanghai branch) phone: +86-21-6841-2050 fax: +86-21-6841-2060 (Beijing branch) phone: +86-20-5881-2026 fax: +86-20-3882-0580 NIKON INSTRUMENTS KOREA CO., LTD. KOREA phone: +82-2-6288-1900 fax: +82-2555-4415 NIKON SINGAPORE PTE. LTD.

SINGAPORE phone: +65-6559-3651 fax: +65-6559-3668 E-mail: NSG.Industrial-sales@nikon.com ISO 14001 Certified for NIKON CORPORATION

ISO 9001 Certified for NIKON CORPORATION Industrial Metrology Business Unit

> PT. NIKON INDONESIA INDONESIA phone: +62-267-864-3949 fax: +62-267-864-3950 E-mail: PTN.Instruments@nikon.com NIKON SALES (THAILAND) CO., LTD. THAILAND phone: +66-2633-5100 fax: 66-2633-5191

Code No. 2CE-INTH-7